### 08000EC203122002

Reg No.:

Name:

## APJ ABDUL KALAM TECHNOLOGICAL UNIVERSI

B.Tech Degree S3 (S,FE) / S1 (PT) (S,FE) Examination June 2024 (20) Scheme

### **Course Code: EC203**

### **Course Name: SOLID STATE DEVICES (EC, AE)**

Max. Marks: 100

### **Duration: 3 Hours**

### PART A

### Answer any two full questions, each carries 15 marks.

a)	Explain Fermi	Dirac	distribution	function.	Plot	the	Fermi	Dirac	distribution	(8)
	function for intrinsic and extrinsic semiconductors.									

- b) What is Einstein Relation? Derive the expression.
- An unknown semiconductor has Eg = 1.1 eV and Nc = Nv. It is doped with  $10^{15}$ (8) 2 a)  $cm^{-3}$  donors, where the donor level is 0.2 eV below Ec. Given that E<sub>F</sub> is 0.25 eV below Ec, calculate ni and the concentration of electrons and holes in the semiconductor at 300K.
  - (7)b) Explain diffusion process in a semiconductor and derive the expression for diffusion current density.
- (8) Define Hall effect. Derive the expression for mobility and carrier concentration 3 a) in terms of Hall voltage.
  - b) Prove that under steady state carrier injection, the injected excess carrier (7) concentration is an exponentially decreasing function of distance.

### PART B

### Answer any two full questions, each carries 15 marks.

- Derive the expression for contact potential and depletion region width of an abrupt (9) 4 a) PN junction at equilibrium.
  - (6) Distinguish between Zener and Avalanche breakdown mechanisms. b)
- Draw the distribution of charge carriers, potential, electric field and charge density (9) 5 a) within the transition region of an abrupt pn junction.
  - b) A silicon abrupt p-n junction at 300K has  $N_A = 10^{16}$  cm<sup>-3</sup> on p-side and  $N_D = 10^{14}$ (6)cm<sup>-3</sup> on n-side. Area of cross-section is 10<sup>-5</sup> cm<sup>2</sup>. Calculate the junction capacitance at equilibrium. Assume ni for silicon at 300K as  $1.5 \times 10^{10}$  cm<sup>-3</sup>

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Marks

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6	a)	Derive Ideal Diode equation and list the assumptions.	(9)						
	b)	With the help of energy band diagrams, explain metal- n type Schottky contact.	(6)						
		PART C							
Answer any two full questions, each carries 20 marks.									
7	a)	Illustrate the minority carrier distribution in a PNP transistor. Plot and mark the	(10)						
-		minority carrier concentrations in the three regions.							
	b)	Draw and explain the structure of FinFET	(5)						
	c)	Draw and explain the transfer characteristics of an enhancement type MOSFET	(5)						
8	a)•	Explain Early effect. What is its effects on Ic, IB, $\alpha$ and $\beta$ of a transistor?	(5)						
	b)	Define the basic performance parameters of BJTs.	(5)						
	c)	With the help of necessary band diagrams, explain equilibrium, accumulation,	(10)						
		depletion and inversion stages of a MOS capacitor.							
9	a)	For a pnp BJT with $N_E < N_B < N_C$ , if $I_{Ep} = 10$ mA, $I_{En} = 100 \mu$ A, $I_{Cp} = 9.8$ mA and	(5)						
		$I_{Cn} = 1 \mu A$ , calculate the base transport factor and emitter injection efficiency.							
	b)	Draw the structure of a PNP transistor and explain the flow of different current	(5)						
		components in a pnp transistor under active mode of operation.							
	c)	Draw and explain the C-V Characteristics of an Ideal MOS capacitor. Derive the	(10)						
		expression for threshold voltage.							

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